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**BEYER WEAVER & THOMAS, LLP**INTELLECTUAL PROPERTY LAW  
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February 17, 2005

**Receiver:** Examiner Julio J. Maldonado  
(USPTO Central Fax)**TEL #:****FAX #:** 703-872-9306**Sender:** Natalie Morgan for:  
Roger S. Sampson**Serial No.** 09/998,993  
**Our Ref. No.:** NOVLP074/NVLS-000414**Re:** Supplement to Response E**Pages Including Cover Sheet(s):** 14**Fax Contents:** Fax Cover Sheet- 1 page  
Amendment Transmittal- 1 page  
Supplement to Response E- 12 pages**MESSAGE:****CONFIDENTIALITY NOTE**

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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of: Turner, et al.

Application No.: 09/998,993

Filed: November 15, 2001

Title: PHOSPHOROUS-DOPED SILICON  
DIOXIDE PROCESS TO CUSTOMIZE  
CONTACT ETCH PROFILES

Attorney Docket No.: NOVLP074 NVLS-  
000414

Examiner: Maldonado, Julio J.  
November 15, 2001

Group: 2823

**CERTIFICATE OF FACSIMILE TRANSMISSION**

I hereby certify that this correspondence is being transmitted by facsimile to fax number 703-872-9306 to the U.S. Patent and Trademark Office on February 17, 2005.

Signed: \_\_\_\_\_

Natalie Morgan

**AMENDMENT TRANSMITTAL**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Transmitted herewith is an Amendment in the above-identified application.

The fee has been calculated as shown below.

	Claims After Amendment		Highest Previously Paid For	Present Extra	Small Entity Rate Fee	Large Entity Rate Fee
Total Claims	25	MINUS	25	0	x 25 =	x 50 = 0
Independent Claims	5	MINUS	5	0	x 100 =	x 200 = 0
Total					\$	\$0

- ☒ Applicant(s) believe that no (additional) Extension of Time is required; however, if it is determined that such an extension is required, Applicant(s) hereby petition that such an extension be granted and authorize the Commissioner to charge the required fees for an Extension of Time under 37 CFR 1.136 to Deposit Account No. 500388.
- ☒ Please charge the required fees, or any additional fees required to facilitate filing the enclosed response, to Deposit Account No. 500388 (Order No. NOVLP074).

Respectfully submitted,  
BEYER WEAVER & THOMAS, LLP

Roger S. Sampson  
Reg. No. 44,314

P.O. Box 70250  
Oakland, CA 94612-0250

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Signed: \_\_\_\_\_

Natalie Morgan

**SUPPLEMENT TO RESPONSE E**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

This paper is submitted in response to the Office Action dated October 29, 2004 ("Office Action") and as a supplement to Response E thereto, filed on January 31, 2005.

Amendments to the Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.

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